

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant	:	Hojo et al.
Appl. No.	:	10/553,083
Filed	:	October 11, 2005
For	:	POSITIVE RESIST COMPOSITION AND METHOD OF FORMATION OF RESIST PATTERN
Examiner	:	C. Hamilton
Group Art Unit	:	1752

AMENDMENT AND RESPONSE TO FINAL OFFICE ACTION

Commissioner for Patents – Box AF
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

In response to the final Office Action mailed **October 15, 2008**, please consider the following amendments and remarks.

Amendments to the claims are reflected in the **listing of claims** which begins on page 2 of this paper.

Remarks begin on page 5 of this paper.